

METHOD OF EXPOSING LAYER WITH LIGHT AND METHOD OF
MANUFACTURING THIN FILM TRANSISTOR SUBSTRATE FOR LIQUID CRYTAL
DISPLAY DEVICE USING THE SAME

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ABSTRACT OF THE DISCLOSURE

To improve product yield, light is scanned on a layer on a substrate through a mask. A pattern is formed on the substrate by the exposure of the layer. The direction of scanning is substantially perpendicular to a longitudinal direction of the pattern. The capacitance difference due to coupling of the pattern to be formed and a
10 conductive layer formed through an insulation layer is reduced. Thus, failures of a display device are reduced and the product yield is increased.